DISPERSED LASER INDUCED FLUORESCENCE OF METALLIC MOLECULAR IONS. IDENTIFICATION OF NEW LOW-LYING ELECTRONIC STATES OF TiCl⁺ AND TiF⁺

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The dispersed laser-induced fluorescence technique has been applied for the first time to metallic molecular ions. The TiCl⁺ and TiF⁺ ions were produced by a high-voltage discharge in helium with traces of TiCl₄ or TiF₄, respectively. A c.w. dye-laser and a grating spectrometer were used to record low-resolution spectra of these species in the visible region. This led to the the observation of new low-lying electronic states of these ions: the $C^3\Pi$ (~1535 cm⁻¹) state of TiCl⁺, the $B^3\Delta$ (~2040 cm⁻¹) and $C^3\Pi$ (~2200 cm⁻¹) states of TiF⁺. The identification of these new states contributes to a better characterization of the first 3000 cm⁻¹ of the energy level diagram of these molecules. The experimental position of the $C^3\Pi$ state of TiCl⁺ is in good agreement with theoretical predictions given by a Ligand Field Theory model.^{*a*} We have extended these calculations to the TiF⁺ isovalent ion, taking advantage of the new experimental data. Both experimental and theoretical new results presented here are expected to help future high-resolution investigations on these species.

^aC. Focsa, M. Bencheikh, and L. G. M. Pettersson, J. Phys. B: At. Mol. Opt. Phys. 31, 2857-2869 (1998).